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(54) Title: DISPENSE VOLUME ADJUSTMENT BASED ON GAP WIDTH OF LOCATED FEATURES

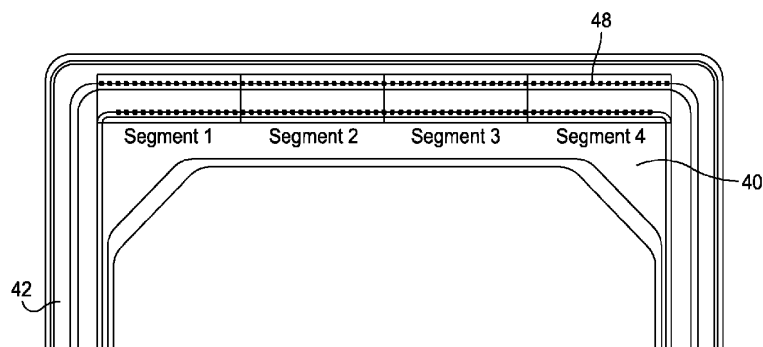


FIG. 4

(57) Abstract: A method of depositing material on an electronic substrate with a dispensing system includes acquiring an image of a first feature of a first component and an adjacent second feature of a second component, performing a measure command to measure an actual distance of a gap between the first feature of the first component and the second feature of the second component, dividing the length of the gap into segments to determine a gap width for each segment, based on the gap width, determining a number of dots to be dispensed by the dispensing unit for each segment, and performing the dispense operation for each segment.



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